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(71) Applicants:

- Sharp Kabushiki Kaisha
 Osaka-shi, Osaka 545-8522 (JP)
- SHARP MICROELECTRONICS TECHNOLOGY, INC.

Camas, WA 98607 (US)

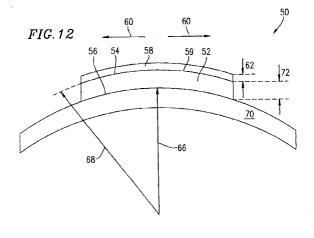
(72) Inventors:

- Hsu, Sheng Teng Camas, WA 98607 (US)
- Yang, Hongning Vancouver, WA 98683 (US)
- Evans, David R.
 Beaverton, OR 97007 (US)
- Nguyen, Tue Vancouver, WA 98683 (US)
- Ma, Yanjun
 Vancouver, WA 98683 (US)
- (74) Representative: Brown, Kenneth Richard et al R.G.C. Jenkins & Co.
 26 Caxton Street London SW1H 0RJ (GB)

(54) Method for deposition of a stressed film

(57) A method has been provided to counteract the inherent tension in a deposited film. A wafer (50) substrate is fixed to a wafer chuck (70) having a curved surface (56). When the chuck surface is convex, a tensile stress is implanted in a deposited film (58). Upon release from the chuck, the deposited film develops a compressive stress. When the chuck surface is concave, a compressive stress is implanted in the deposited

film. Upon release from the chuck, the deposited film develops a tensile stress. Loading a film with a compressive stress is helpful in making films having an inherently tensile stress become thermal stable. Stress loading is also used to improve adhesion between films, and to prevent warping of a film during annealing. A product-by-process using the above-described method is also provided.





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